	Hits	Search Text	DBs
22	139	((first near4 (mask or reticle or phase$3shift$4mask or photomask)) same ((second or third or multiple) near5 (mask or reticle or phase$3shift$4mask or photomask))) and (first same (mask or reticle or photomask) same second same phase same (invers$3 or revers$3 or shift$4) same (light or beam or radiation or illuminat$4)) and (auxiliary or serif$3 or dummy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
23	113	((first near4 (mask or reticle or phase$3shift$4mask or photomask)) same ((second or third or multiple) near5 (mask or reticle or phase$3shift$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers$3 or shift$4) same (light or beam or radiation or illuminat$4) same (expos$4 or irradiat$4 or illuminat$4)) and (auxiliary or serif$3 or dummy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
24	27	((first near4 (mask or reticle or phase$3shift$4mask or photomask)) same (defect or error) same ((second or third or multiple) near5 (mask or reticle or phase$3shift$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers$3 or shift$4) same (light or beam or radiation or illuminat$4) same (expos$4 or irradiat$4 or illuminat$4)) and (auxiliary or serif$3 or dummy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
25	6	((first near4 (mask or reticle or phase$3shift$4mask or photomask) near16 (defect or error)) same ((second or third or multiple) near5 (mask or reticle or phase$3shift$4mask or photomask) near16 (defect or error))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers$3 or shift$4) same (light or beam or radiation or illuminat$4) same (expos$4 or irradiat$4 or illuminat$4)) and (auxiliary or serif$3 or dummy)	US-PGPUB
26	46	430/311.ccls. and ((first near4 (mask or reticle or phase$3shift$4mask or photomask)) same ((second or third or multiple) near5 (mask or reticle or phase$3shift$4mask or photomask))) and (first same ((mask or reticle or photomask) near16 second) same phase same (invers$3 or shift$4) same (light or beam or radiation or illuminat$4) same (expos$4 or irradiat$4 or illuminat$4)) and (auxiliary or serif$3 or dummy)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB